

Notice of References Cited	Application/Control No. 10/537,042	Applicant(s)/Patent Under Reexamination DE LA VEAUX ET AL.	
	Examiner NATASHA YOUNG	Art Unit 1797	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-3,586,489	06-1971	Hilgers et al.	422/158
	B	US-			
	C	US-			
	D	US-			
	E	US-			
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
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	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Gruenberger et al, Continuous Production of Fullerenes and Other Carbon Nanomaterials on a Semi-Industrial Scale using Plasma Technology, October 14, 2002, American Institute of Physics, Vol 633, pp. 7-11.
	V	
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.